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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Gennari

Attorney Docket No.:
UCALP011X1/B02-005-3

Application No.: 10/716,266

Examiner: MERLINO, AMANDA H

Filed: November 17, 2003

Group: 2877

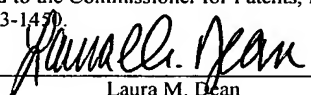
Title: METHOD OF LOCATING AREAS IN AN
IMAGE SUCH AS A PHOTO MASK LAYOUT
THAT ARE SENSITIVE TO RESIDUAL
PROCESSING EFFECTS

Confirmation No.: 6483

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on June 29, 2005 in an envelope addressed to the Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Signed: _____


Laura M. Dean

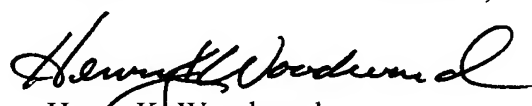
SEPARATE LETTER TO THE OFFICIAL DRAFTSMAN
REQUESTING ENTERING OF FORMAL DRAWINGS
(MPEP 608.02(p))

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed are substitute (formal) drawings for the above-identified patent application. If the Draftsman has any question concerning these drawings, he or she is respectfully requested to contact the undersigned.

Respectfully submitted,
BEYER WEAVER & THOMAS, LLP


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